

#6/Election
NIT-215
Attn
3/22/02

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

S. KONDO et al

Serial No. 09/637,570

Filed: August 14, 2000

Group Art Unit: 28

Examiner: Ha T. Nguyen

For: POLISHING METHOD, METALLIZATION FABRICATION
METHOD, METHOD FOR MANUFACTURING SEMICONDUCTOR
DEVICE AND SEMICONDUCTOR DEVICE

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RESPONSE TO RESTRICTION REQUIREMENT

Commissioner of Patents
Washington, D.C. 20231

Sir:

In response to the Restriction Requirement mailed
February 19, 2002, Applicants elect to prosecute the invention
defined by the Examiner as Group I, including claims 1-21.
This election is made without traverse.

The Commissioner is hereby authorized to charge any
additional payment due to deposit account no. 50-1417.

Respectfully submitted,

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